	<u>위 (의) 후 () 후</u> Es : 중) <u>존대하며 (주의</u>	Chan. ESiando States 22 Hale.	
£t.	### ##################################	DBW USPAT, US-PGPUB; EPO; JPO; DERMENT; IBM TDB	71ms 2004/09/
	((237/532.cols: 438/957.cols:) and (metal adj oxide and capacitor)) and buffer and @pd>20031214	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/09/
7	(257/532.ccls, 438/957.ccls.) and (matal adj oxide and cepacitor) and 0pd>20040415	USPAT; US-PGPUB; EPO; JPO; DERWENT; IRM_TDB	2004/09/
	((257/532.ccls. 438/957.ccls.) and (metal adj oxide adj (buffer or layez)) and capacitor) and @pd>20031214	USPAT; US-PGPUB; EPO; JPO; DERMENT; IBM_TDB	2004/09/
	((tungsten ad) (oxide or trioxide)) and ((tungsten ad) nitride) with electrode) and @pd>20031214	uspat; us-pgpub; epo; jpo; derwent; ibm_tdb	2004/09/
	((257/512; ccls: 438/957; ccls:)) and (metal adj oxide and capacitor)) and buffer and 9pd>20031214	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/
	'(257/532.ccls: 438/957.ccls:) and (metal adj.oxids and capacitor) and 9pd>20031214	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/
	((257/532;ccls: 438/957.ccls:)) and:(metal adj oxide and:capecitor)) and buffer and @pd>20031214	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/
N.V.	((257/532.ccls: 438/957.ccls.) and (metal adj oxide and capacitor)) and buffer and @pd>20040415	USPAT; US-PGPUB; EPO; JPO; DERMENT; IBM_TDB	2004/09/
	(((257/532.ccls. 438/957.ccls.)) and (metal adj oxide adj (buffer or layer)) and capacitor) and @pd>20040415	USPAT; US-PGPUB; EPO; JPO; DERMENT; IBM_TDB	2004/09/
	((tungsten adj (oxide or trioxide)) and ((tungsten adj nitride) with electrode) and @pd>20040415	USPAT; US-PGPUB; EPO; JPO; DERMENT; IEM_TDB	2004/09/
	((257/532.ccls. 438/957.ccls.) and (metal adj oxide and capacitor)) and buffer and 9pd>20040415	USPAT; US-PGPUB; EPO; JPO; DERMENT; IBM_TDB	2004/09/
	((257/532.ccls. 438/957.ccls.)) and (matal adj oxide adj (buffer or layer)) and capacitor) and @pd>20031214	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/
	((257/532.ccls. \$38/957.ccls.) and (metal adj oxide and capacitor)) and buffer and @pd>20031214	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/
	(((257/532,ccls. \$38/957,ccls.) and (metal adj oxide and capacitor)) and buffer and #pd>20040415	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/
	((257/532:ccls: 439/557:ccls:); and (metal adj oxide adj (buffer or layer)); and capacitor); and @pd>20040415	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/
	((257/532.ccls. 438/957.ccls.) and (metal adj oxide and capecitor)) and buffer and 9pd>20040415	USPAT; US-PGPUB; EPC; JPO; DERWENT; IRM_TDB	2004/09/
	20020070414.pn. ((257/532.ccis. 438/957.ccis.) and (metal adj oxide and capacitor) and 8pd>20040415) (((257/532.ccis. 438/957.ccis.)) and (metal adj oxide adj (oxide adj (oxide or layer)) and apacitor) and 8pd>20040415) ((tungstam adj (oxide or layer)) and (pd>20040415) ((tungstam adj (oxide or layer)) and (pd>20040415) ((257/532.ccis.)) and (pd>20040415) ((257/532.ccis.))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/
	257/296,300,906,315.ccls.: and:@pd>20031214	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/
	257/296,300,906,315.cals. and 6pd>20040415	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/
1	(257/532.ccls. 438/957.ccls.) and (metal adj oxide and capacitor) and 0pd>20040415	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/
7	(257/532.cols, 438/957.cols.) and (metal adj oxide and capacitor) and 0pd>20040415	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/

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